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<td>大貫 憲睦 小松 武美 古川 昭雄 咲野 弘 稲田 ルミ子 田沼 静一</td>
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Anderson Localization of \(1T-TaS_2\)

Yoshichika ONUKI and Takemi KOMATSUBARA
Institute of Materials Science, University of Tsukuba, Sakura-mura, Ibaraki 305 Japan
and
Akio FURUKAWA, Hirashi NAGANO, Rumiko INADA and Sei-ichi TANUMA
The Institute for Solid State Physics, The University of Tokyo, Roppongi, Minato-ku, Tokyo 106 Japan

\(1T-TaS_2\) with a layered structure has been recently investigated by many researchers because it has a strong charge density wave (CDW) fully to destroy the original Fermi surface and shows Anderson localization at low temperatures. The main origin of this localization is crystalline defects. \(1T\)-phase of \(TaS_2\) is stable above 750°C and is retained at room temperature by quenching, which introduces the vacancies in the crystal. Furthermore, the constitutional tantalum is self-intercalated in the Van der Waals gap site during the crystal growth. The present paper reports the electrical and magnetic properties of \(1T-TaS_2\) with different intra- and inter-layer crystalline defects\(^{1-3}\).

(1) Electrical resistivity

Figure 1 shows the temperature dependence of electrical resistivity for two typical samples.

**Fig. 1** Temperature dependence of \(1T-TaS_2\) (A & C-samples).

**Fig. 2** Electrical resistivity of \(1T-TaS_2\) in the temperature region of 10K to 0.1K, where the abscissa is taken as \(T/T_0\).
Growth temperatures are 950°C (A-sample) and 880°C (C-sample), respectively, as shown in the insert of Fig.1. The A-single crystal was grown in the hotter part of the quartz tube where the powder materials were put out. On the other hand, the C-single crystal was grown at the lower temperature part where the excess sulphur vapor is high in the density. Therefore, the A-sample should have much crystalline (inter-layer) defect compared with the C-sample. The resistivity increase at low temperatures is due to the variable range hopping conduction of Anderson localization, which is enhanced for the A-sample with a much defect.

Furthermore, Fig.2 shows the electrical resistivity of 1T-TaS₂ at lower temperatures, ca. 10-0.1K, where the temperature axis of abscissa is taken as $T^{-1/2}$. The logarithmic resistivity data for 1T-TaS₂ with different crystalline defects fit with a $T^{-1/2}$ dependence, which is the same result for the previous data by Kobayashi and Muto4) and the present authors5). On the other hand, it is not in agreement with the $T^{-1/3}$ one by DiSalvo and Graebner6), which is simply expected in the possible quasi-two dimensional nature of the layered material.

(2) Hall coefficient

Figure 3 shows the temperature dependence of Hall coefficient of 1T-TaS₂. At a nearly commensurate - commensurate CDW transition of $T_d = 200$K, the electrical resistivity increases from $2 \times 10^{-3}$Ω.cm to $3 \times 10^{-2}$Ω.cm when the temperature is lowered and the corresponding carrier concentration decreases from $4 \times 10^{21}$ cm$^{-3}$ (a negative Hall coefficient) to $4 \times 10^{19}$ cm$^{-3}$ (a positive one) under a single carrier model1,7) The Hall coefficient for the A-sample with a much defect has a peak around 20-40K, while constant for the C-sample with less defects.

(3) Magnetoresistivity

Large positive and negative magnetoresistances associated with the Anderson localization in 1T-TaS₂4) by Kobayashi and Muto and the present authors5). The negative magnetoresistance was explained by Fukuyama and Yosida in such a way that
the highest occupied state has an upward linear Zeeman shift to make the energy difference between the mobility edge $E_C$ and the Fermi energy $E_F$ smaller under magnetic fields and to make the hopping conduction larger. Figure 4 shows an overall trend of magnetoresistances from negative to positive with the increase of temperature, which has been explained in the following way by Kamimura, Takemori and Kurobe. For the localized electrons which make hopping conduction, the intra-site and inter-site correlations should be taken into account. For the former correlation, four kinds of hopping processes exist as shown in Fig.5, where $SO$, $UO$ and $DO$ mean singly occupied, unoccupied and doubly occupied states, respectively, and $U$ the correlation energy. All of these four processes contribute to the conductivity in the absence of magnetic field. The processes $SO$-$SO$ and $DO$-$UO$ trend to be suppressed under the applied field. Therefore, the positive magnetoresistance increases with the increase of magnetic field and saturates above a certain field, while the Zeeman effect dealt by Fukuyama and Yosida decreases the magnetoresistance. The magnetoresistance is then expected to have a maximum at a certain field, as shown in Fig.4. At low enough temperature, the inter-site correlation plays such a role that an antiferromagnetic coupling between two SO-states stops the spin flip under the field and the suppression of SO-$SO$ and DO-$UO$ transitions are released. Thus the negative magnetoresis-
tance takes place due to the Zeeman effect again.

(4) Magnetic susceptibility

Figure 6 shows the temperature dependence of magnetic susceptibilities of 1T-TaS$_2$ and 1T-TaS$_{1.7}$Se$_{0.3}$. The susceptibility consists of a diamagnetic part and a paramagnetic one. The paramagnetic contribution appears below ca. 100K and shows a Curie like temperature dependence, which is not due to the magnetic impurities but due to the correlation effect of Anderson localized electrons. Replacing sulphur by selenium makes a intra-layer random potential, which scarcely changes the carrier concentration and enhances the localization. Namely, a density of the paramagnetic moments of about one in $10^3$ Ta atoms is twice larger than the one of 1T-TaS$_2$.

References

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